

µLens enhanced SiPMs





Outline

- Context the LHCb SciFi Upgrade II
- The concept developed for μ Lens arrays on SiPMs
- Simulation
- Measurements
 - PDE
 - Cross-talk
 - SPTR





PhD thesis Olivier Girard PhD thesis Axel Kuonen

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SciFi Tracker LHCb Upgrade I (2019)







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Light source angular distribution (SciFi)

- Plastic optical fibre (POF) with 250µm diameter, double cladded multimode
- NA=0.72 = n sin (numerical aperture)



A narrow angular distribution (small NA) can lead to a performant optical focusing. For this fibre, the lost photons at the production (only trapped 5.35%) introduces a angular selection

-> Narrow angular distribution is also true for (LHCb) RICH, LiDAR, camera sensors commercial CCD,CMOS

Not for applications where an optical dense material is directedly in contact with the SiPM silicon, LYSO readout TOFPET, LAr

Measured vs Simulation: Fibre exit angle distribution

Measured: short fibre (25cm) Measured: Long fibre (230cm) Reweighted Intensity [a.u.] 70.06 70.0700.07 70. Double Cladding <u>n</u>.0.06 Double Cladding - Single Cladding, Green Single Cladding, Green - Single Cladding, Blue Single Cladding, Blue Intensity 0.05 Reweighted] 0.03 0.01 0 0 20 30 4020 30 0 1050 60 7010 40 50 60 70 0 Angle [°] Angle [°] Simulated: short fibre (25cm) After some distance (240cm) Double cladded fibre Entries Total this mode is strongly has a propagation 4000 Core (no refraction) suppressed and the exit mode that introduces Core (refraction at IC) 3500 ction at OC angle distribution is a larger exit angle 3000 IC (no refraction) distribution. narrower! IC (refraction at core) 2500 IC (refraction at OC) 2000 OC The simulation of the POF is difficult to tune to obtain 1500 to angular distribution at different propagation modes. 1000 Attenuation and surface quality is difficult to model. 500 Base the studies on measurements. 10 20 30 70 80 40 50 Exit angle (°)

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Influence of the fibre surface



Pixel outline of a high density SiPM







How can a refractive lens be used most efficiently ?





Require both new pixel layout, connectivity?

Are inefficient where the dead regions are.





Spherical lenses one-in-two "checkerboard structure"



Lens concentrates the light into the active region and avoids all dead borders

Efficient pixel region without lens

- High GFF SiPMs will profit less from the MLA eg. (GFF=81.5% -> 100%)
- To reach maximal PDE, don't reduce the GFF of the SiPM, decrease the dead region illumination

µLens production steps, limitations



(j) MLA stripping

Wafer / bare die

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The lens implementation (parameters)



- Inter-lens gap >1μm
- Ratio Lens height / Lens radius (80%) for demolding angle < 75°
- Residual layer thickness > 10µm (depending on the total surface)
- Alignment precision >1μm

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µLens on SPADs

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Critical to reach a minimal distance between lenses, 1μ m is equivalent to $(39/40)^2=0.95 \rightarrow 5\%$ area loss

C. Bruschini, I. Antolovic, F. Zanella, A. Ulku, S. Lindner, A. Kalyanov, T. Milanese, E. Bernasconi, V. Pešić, and E. Charbon, "Challenges and prospects for multi-chip microlens imprints on front-side illuminated SPAD imagers," Opt. Express 31, 21935-21953 (2023).



µLens on SPADs: Concentration factor





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- Lower concentration factor with larger NA
- Thinner residual layer is required for larger NA
- Largest possible lens sag is ideal

Implementation of MLAs for this design reaches PDE of +100%

C. Bruschini, I. Antolovic, F. Zanella, A. Ulku, S. Lindner, A. Kalyanov, T. Milanese, E. Bernasconi, V. Pešić, and E. Charbon, "Challenges and prospects for multi-chip microlens imprints on front-side illuminated SPAD imagers," Opt. Express 31, 21935-21953 (2023).

Simulation





Simulation results I

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- The quantity to optimise is the ratio between detected and incident photons, without lenses it is proportional to "GFF", with lenses it is called "EGFF" (effective)
- We calculate the enhancement in light detection " LY_{enh} " Best values for a pixel size of 41.7 μ m are:
- R_{lens} is best at 95% of the maximal radius resulting in an inter-lens gap of 2.95μm
- H_{Lens} is best when the lens has the maximal height (Θ =75° or 22µm)
- RLT is critical and is the free parameter during the lens replication (not defined at the master production) best at 12.5μm

GFF=81.5% but no low field region)

Low field region, 2µm with 60% efficiency GFF=75.5%

FBK, pixel size $41.7\mu m$, GFF= 81.5% , light source SciFi				
$H_{Lens}[^{\circ}]$	$RLT[\mu m]$	LY_{enh} [%]		
65	10	13.35		
	12.5	15.15		
	15	15.52		
	17.5	15.13		
70	10	15.88		
	12.5	17.22		
	15	16.83		
	17.5	16.29		
75	10	18.17		
	12.5	18.59		
	15	17.12		
	17.5	16.12		

FBK, pixel size: $41.7\mu m$ GFF: 81.5% , light source SciFi			
$RLT[\mu m]$	LY_{enh} [%]		
10	24.54		
12.5	24.57		
15	23.68		
17.5	22.11		
	EGFF=94.1%		
EGFF=96.79	%		

Simulation results different light source



• Simulation for different pixel size and GFF

Set:

- H_{Lens} maximal height (Θ =75°)
- R_{Lens} = 95% lens radius
- RLT = 12.5μm for 41.7μm pixel
- RLT = $10\mu m$ for $31.3\mu m$ pixel
- Low efficient region, 2µm at 60%

GFF[%]	Light source	$LY_{enh}[\%]$		
FBK, pixel size: $41.7 \mu m$				
81.5	SciFi	24.57		
	Narrow	27.91		
HPK, pixel size: $41.7\mu m$				
68.5	SciFi	38.98		
	Narrow	45.93		
FBK, pixel size: $31.3\mu m$				
77.7	SciFi	27.51		
	Narrow	39.87		

EGFF=94.1% EGFF=96.7%	
EGFF=88.2% EGFF=92.7%	
EGFF=89.6% EGFF=96.3%	



EΡ۶

Chen Zhang et al, "Methodology for measuring the fill factor of silicon photomultipliers", https://doi.org/10.1016/j.measurement.2023.112720.

The implementation

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Custom silicon from FBK (NUV-HD)

- Pixel size 41.7μm
- 64-channel, segmentation to 1.6mm x 0.25mm=0.4mm² (we should use the segmentation to check uniformity of the MLA)

Lens parameters nominal:

- H_{Lens} maximal height (Θ=75°) (22μm)
- R_{Lens} = 95% lens radius
- RLT = 12.5µm

Super reticles for lens replication 2x2 and 4x4



Alignment between silicon structure and MLA





Alignment QA is performed with the relative position of small lenses placed at the alignment markers on the silicon Obtained 1-2µm deviation in x or y direction

Flat layer coating for reference and comparison with MLA

To compare a conventional polymer coating, a flat layer with same polymer as MLA is produced.





EΡ

PDE with low NA<0.05 light source





- PDE increase is at its maximum at low overvoltage -> confirms the low field region at the pixel boarders are less illuminated
 Over-voltage 2V:
- Simulation (27.9%) vs measurement (22%) Over-voltage 8V:
- Simulation (24.6%) vs measurement (17%)



Gain and cross-talk

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- Gain remains constant
- X-talk is reduced by 40%, μLens surface is reducing external cross-talk

LY with fibre module Scifi angular distribution







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• Short (20cm) 20%

• Long (230cm) measured 23% vs simulation 24.6%

SPTR and time resolution improves with MLA



- SPTR measured with oscilloscope, single photon signal only
- Corrected for amplitude induced time walk (CFD)
- Scan of best timing threshold
- Detector on Kapton flex PCB

The uLens acts like a mask around the pixel boarders. Better SPTR has been reported.

Gundacker, S., Borghi, G., Cherry, S., Gola, A., Lee, D., Merzi, S., Penna, M., Schulz, V. & Kwon, S. On timing-optimized SiPMs for Cherenkov detection to boost low cost time-of-flight PET. Physics In Medicine And Biology. 68 (2023,8)



Summary

- High GFF SiPMs have been enhanced with MLAs and an improvement of 22% for low over-voltage (2V) and 17% for high over-voltage have been measured.
- MLAs can also improve SPTR, cross-talk and are particularly useful for operation with radiation as the best PDE improvement is at low overvoltage.
- The light source of SciFi (NA<0.72) is sufficiently small to have a large improvement similar to a very narrow normal incident light source.
- Critical for the implementation are RLT control (limit of the technology 10μm) and the alignment precision during the replication should be better than 2μm.
- Moving to larger mold is desired, large quantity replication at low cost when wafer level replication can be performed.